Sakae Tanemura

List of Publications by Year in descending order

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331670 580821 2,030 26 21 25 citations h-index g-index papers 26 26 26 2429 docs citations times ranked citing authors all docs

#	Article	IF	CITATIONS
1	Strategies for breaking theoretical evaporation limitation in direct solar steam generation. Solar Energy Materials and Solar Cells, 2021, 220, 110842.	6.2	47
2	Flame-treated and fast-assembled foam system for direct solar steam generation and non-plugging high salinity desalination with self-cleaning effect. Applied Energy, 2019, 241, 652-659.	10.1	85
3	Extremely high water-production created by a nanoink-stained PVA evaporator with embossment structure. Nano Energy, 2019, 55, 368-376.	16.0	86
4	A mimetic transpiration system for record high conversion efficiency in solar steam generator under one-sun. Materials Today Energy, 2018, 8, 166-173.	4.7	145
5	A Novel Inkâ€Stained Paper for Solar Heavy Metal Treatment and Desalination. Solar Rrl, 2018, 2, 1800073.	5.8	49
6	The emergence of solar thermal utilization: solar-driven steam generation. Journal of Materials Chemistry A, 2017, 5, 7691-7709.	10.3	255
7	Morphology Control of Ag Polyhedron Nanoparticles for Costâ€Effective and Fast Solar Steam Generation. Solar Rrl, 2017, 1, 1600023.	5.8	72
8	Ellipsometric studies of optical properties of Er-doped ZnO thin films synthesized by sol–gel method. Thin Solid Films, 2013, 543, 125-129.	1.8	17
9	Efficient, low-cost solar thermoelectric cogenerators comprising evacuated tubular solar collectors and thermoelectric modules. Applied Energy, 2013, 109, 51-59.	10.1	98
10	A facile process to prepare copper oxide thin films as solar selective absorbers. Applied Surface Science, 2011, 257, 10729-10736.	6.1	107
11	Effect of annealing temperature on optical properties of Er-doped ZnO films prepared by sol–gel method. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2008, 148, 35-39.	3.5	47
12	Structural and Optical Characterization of Semiconducting TiN Nanoparticles Thin Film. Japanese Journal of Applied Physics, 2007, 46, 356-361.	1.5	7
13	Low resistivity p-ZnO films fabricated by sol-gel spin coating. Applied Physics Letters, 2006, 88, 251116.	3.3	96
14	The improvement of optical reactivity for TiO2 thin films by N2–H2 plasma surface-treatment. Journal of Crystal Growth, 2004, 260, 118-124.	1.5	98
15	Fabrication, characterization and Raman study of anatase-TiO2 nanorods by a heating-sol–gel template process. Journal of Crystal Growth, 2004, 264, 246-252.	1.5	134
16	Heating-sol–gel template process for the growth of TiO2 nanorods with rutile and anatase structure. Applied Surface Science, 2004, 238, 175-179.	6.1	83
17	IR properties of SiO deposited on V1â^'xWxO2 thermochromic films by vacuum evaporation. Thin Solid Films, 2000, 375, 100-103.	1.8	8
18	New material design with V1â^'xWxO2 film for sky radiator to obtain temperature stability. Solar Energy, 1998, 64, 3-7.	6.1	29

#	Article	IF	CITATIONS
19	Optical constants of V_1-xW_xO_2 films. Applied Optics, 1998, 37, 1858.	2.1	84
20	CROSS-SECTIONAL OBSERVATIONS BY HRTEM OF THE STRUCTURE OF NICKEL OXIDE ELECTROCHROMIC THIN FILMS IN THE AS-DEPOSITED STATE AND THE BLEACHED STATE. Materials Research Bulletin, 1997, 32, 839-845.	5.2	8
21	Thin film used to obtain a constant temperature lower than the ambient. Thin Solid Films, 1996, 281-282, 232-234.	1.8	23
22	Characterization of niobium oxide electrochromic thin films prepared by reactive d.c. magnetron sputtering. Thin Solid Films, 1996, 281-282, 235-238.	1.8	63
23	Relationship between Transition Temperature and x in V1- xW xO2 Films Deposited by Dual-Target Magnetron Sputtering. Japanese Journal of Applied Physics, 1995, 34, 2459-2460.	1.5	98
24	<title>Formation of V<formula><inf><roman>1-x</roman></inf></formula>W<formula><inf><roman>x</roman></inf></formula>O thermochromic films by reactive magnetron sputtering with an alloy target</title> ., 1995, , .	<formula></formula>	<inf><romar< td=""></romar<></inf>
25	Nickel Oxide Electrochromic Thin Films Prepared by Reactive DC Magnetron Sputtering. Japanese Journal of Applied Physics, 1995, 34, 2440-2446.	1.5	169
26	Formation and Thermochromism of VO2Films Deposited by RF Magnetron Sputtering at Low Substrate Temperature. Japanese Journal of Applied Physics, 1994, 33, 1478-1483.	1.5	122